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The Quest for Low Loss High Refractive Index Dielectric Materials for UV Photonic Applications

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Received: 26 September 2018; Accepted: 22 October 2018; Published: 25 October 2018



Abstract: Nanostructured High Refractive Index (HRI) dielectric materials, when acting as nanoantennas or metasurfaces in the near-infrared (NIR) and visible (VIS) spectral ranges, can interact with light and show interesting scattering directionality properties. Also, HRI dielectric materials with low absorption in these spectral ranges show very low heat radiation when illuminated. Up to now, most of the studies of these kind of materials have been explored in the VIS-NIR. However, to the best of our knowledge, these properties have not been extended to the ultraviolet (UV), where their application in fields like photocatalysis, biosensing, surface-enhanced spectroscopies or light guiding and trapping can be of extraordinary relevance. Here, we present a detailed numerical study of the directional scattering properties, near-field enhancement and heat generation of several materials that can be good candidates for those applications in the UV. These materials include aluminum phosphide, aluminum arsenide, aluminum nitride, diamond, cerium dioxide and titanium dioxide. In this study, we compare their performance when forming either isolated nanoparticles or dimers to build either nanoantennas or unit cells for more complex metasurfaces.

Keywords: high refractive index dielectrics; UV plasmonics; scattering

1. Introduction

Plasmonics has been an extremely active area of research in the last decade [1]. The potential of using metallic nanoparticles (NPs) as electromagnetic field enhancers has opened up new possibilities in fields like chemistry, surface-enhanced spectroscopies, nanosensing, and medicine [2]. Although, in general, metallic NPs exhibit good plasmonic performance [3,4], their intrinsic Joule losses limit their use for many applications [5,6]. To overcome this problem, a lot of attention has been paid to dielectric nanostructures made of High-Refractive-Index (HRI) materials, working in the Visible (VIS) and Near-infrared (NIR) ranges. These materials are characterized by a high real part n > 2 and a low imaginary part $k \approx 0$ of their refractive indices (some examples can be found in ref. [7]). They show the "ability" of enhancing the electromagnetic field both in the near and far field regimes without much absorption [5,6,8,9] in those spectral ranges. In addition, they support magnetic resonances originated from the excited displacement currents. Moreover, HRI dielectric NPs manifest interesting properties of scattering directionality arising from the coherent effects between the excited electric and magnetic dipolar components [9–11]. Under some specific conditions, scattered radiation from a single HRI dielectric spherical nanoparticle can be concentrated either in the backward or forward scattering regions. When the electric and magnetic dipoles oscillate in- or out-of-phase, two special situations appear, the so-called "zero-backward condition" (null scattering in the backward direction) and the "minimum forward condition" (minimum scattering in the forward direction), respectively. Up to now, most of the studies concerning these effects have been done in the visible (VIS) and near-infrared (NIR) ranges using common semiconductors such as Si [12,13] or GaAs [14], because of their interest for optical communications applications.

Unlike metals, when HRI dielectric materials show negligible absorption in the VIS-NIR spectral ranges (see ref. [7] for some examples), no localized heat appears. Consequently, neither the surrounding medium nor the nanostructure is heated, something that could have a clear negative effect. For instance, it could limit the performance of nan-antennas [15,16] by altering the refractive index of both the nanostructure and surrounding medium through the thermo-optic effect [17]. Also, depending on the incident power, the nanoantenna could be reshaped, or even melted [18]. In addition, the heat generated by the nanoparticle can either vaporize the solvent media, affect or even destroy molecules and proteins. Heat can also affect the SERS signal, and has connection to problems or anomalies found in several processes including thermal annealing, modified adsorption/desorption kinetics of surface molecules, and changes in the dielectric properties of both, medium and particle [19]. In consequence, HRI dielectric materials have been proposed as an alternative to metals in surface-enhanced spectroscopies [5,6].

Extending plasmonics into the UV (3–6 eV or 200 < wavelength < 400 nm) has triggered immense interest due to new challenges arising in specific areas [20]. For example, many biological compounds such as nucleotide bases, nucleic acids, or aromatic amino acids in cells have absorption bands in the ultraviolet (UV). By using the local electric field enhancement generated by nanoparticles when illuminated at resonant wavelength, surface enhanced spectroscopy techniques [21–23] (SERS, TERS, etc.) can be improved to ease the detection of biomolecules. Other biosensing techniques rely on monitoring the spectral shifts induced by some target analytes in the extinction peaks of the NPs acting as nanoantennas. Bioimaging can also benefit from using UV radiation, since the diffraction limit is proportional to the wavelength (the lower the wavelength the higher the resolution). Photocatalytic processes take also advantage of the UV radiation [24–26]. This area has experienced a great development in the last decade. In photocatalysis, photons are used to activate chemical reactions by offering product selectivity. This effect can be enhanced by plasmonic metals by using metal-semiconductor nanostructures, like Au-TiO₂ decorated particles [27,28]. However, more recently it was demonstrated that metallic NPs can drive chemical reactions on their own [29]. Most of these studies on UV plasmonics have been done using metals with strong UV plasmonic response such as aluminum, magnesium, gallium, or rhodium [20,30], but, to the best of our knowledge, HRI dielectric NPs have not been explored in this spectral range yet.

Here we present a numerical analysis of several candidate dielectric materials that show HRI dielectric properties at energies above 3 eV. The dielectric materials chosen for this study are aluminum phosphide (AlP), aluminum arsenide (AlAs), aluminum nitride (AlN), diamond, cerium dioxide (CeO₂), and titanium dioxide (TiO₂). TiO₂ and CeO₂ are commonly used in photocatalysis [31,32]. AlN, AlP, and AlAs have undergone extensive study because of their potential use in the fabrication of light-emitting diodes (LEDs) [33]. In fact, in 2010 an AlN LED was presented with an emission wavelength of 210 nm, the shortest ever reported [34]. AlP and AlAs are materials commonly alloyed with GaP and GaAs to form AlGaP and Al_xG_{1-x}As for their use in LED design. Nanodiamonds are being used in several areas of research and for various applications that include catalysis, drug delivery, and biomedical imaging [35].

The analysis of the aforementioned materials consists in a detailed numerical investigation of their directionality properties and their near-field enhancement in the UV. For the sake of comparison, we specifically consider isolated spheres of different sizes. It is worth mentioning that the results obtained for the spheres can be generalized for other NP's shapes. To mimic common typical experimental conditions, interaction effects in dimers are explored by comparing the near-field enhancement and the temperature generated in the nanoparticles and its surroundings.

This work is aimed to introduce some HRI dielectric materials that can offer high quality directional properties and high near-field enhancement without heat generation in the UV regime. These features are closely connected with UV light-trapping applications and sensing. We envision

that this study can open a new landscape for optimizing the efficiency of solar energy harvesting, photocatalysis, photodetection, and spectroscopic techniques in the UV regime.

The work is organized as follows. In Section 2, we briefly review the theoretical concepts and methods used to perform the electromagnetic and temperature calculations. In Section 3, we describe the criteria used to select the analyzed materials. In addition, the optical properties of these materials are presented. Section 4 includes the results and discussion of this research: an analysis of the near-field enhancement, directionality properties and cooperative effects in spherical NPs made of the selected materials. Finally, in Section 5 the main conclusions of this work are summarized.

2. Methods

2.1. Electromagnetic Simulations

The electromagnetic interaction between isolated nanospheres and light has been modeled following the Lorenz-Mie formalism for scattering and absorption of light by small particles [36,37]. The scattering efficiency by a spherical particle is given by

$$Q_{sca} = \frac{2}{x^2} \sum_{n=1}^{\infty} (2n+1) (|a_n|^2 + |b_n|^2),$$
(1)

where a_n and b_n are the scattering coefficients of the Lorenz-Mie theory. These depend on both particle size and optical properties of the NP relative to its surrounding medium. The size parameter x is given by $2\pi m_{med}R/\lambda$, where λ is the wavelength of incident light in the surrounding medium of refractive index m_{med} , and R is the radius of the sphere. From a physical point of view, coefficients a_n and b_n represent the weighting factors of the different multipolar contributions of order n, electric or magnetic, respectively. In particular, a_1 and b_1 correspond to the electric and magnetic dipolar modes, respectively. When $a_1 = b_1$ the zero backward condition is fulfilled and, as a result [9], there is null scattering in the backward direction, assuming that the rest of the coefficients are negligible (small size limit).

In the far-field region, the scattered electric field E^{sca} is related to the incident one E^{inc} through the scattering amplitude matrix $S(\theta, \phi)$ [36]. The scattered *p*-/*s*-components are given by

$$\begin{pmatrix} E_p^{sca} \\ E_s^{sca} \end{pmatrix} \propto \begin{pmatrix} S_2(\theta,\phi) & S_3(\theta,\phi) \\ S_4(\theta,\phi) & S_1(\theta,\phi) \end{pmatrix} \begin{pmatrix} E_p^{inc} \\ E_s^{inc} \\ E_s^{inc} \end{pmatrix},$$
(2)

where θ and ϕ are the scattering and azimuthal angles, respectively. The $S_i(\theta, \phi)$ elements are related to the coefficients a_n and b_n , and specific angular functions [36].

In order to quantify the efficiency of the zero backward scattering condition, the forward to backward scattering intensity ratio (I_{Fwd}/I_{Bck}) is introduced. This magnitude is defined as the ratio between the integrated scattered intensity in the forward and backward hemispheres. A key point to consider is that although a particle can have a high value of I_{Fwd}/I_{Bck} , its scattering efficiency may be negligible, making its scattering directionality properties useless. Therefore, it is important to find NPs made of materials that have high values of both I_{Fwd}/I_{Bck} and Q_{sca} [38]. Keeping this in mind, we have evaluated the product between these two magnitudes: $Q_{ZB} = I_{Fwd}/I_{Bck} \cdot Q_{sca}$. We will refer to this magnitude as *zero backward efficiency* (Q_{ZB}).

As aforementioned, the electromagnetic response of the nanospheres excited with light has been modeled using the Lorenz-Mie formalism. On the other hand, the interaction of light with dimers has been solved with finite element (FEM) calculations through commercial software COMSOL Multiphysics 5.2 (COMSOL Inc., Burlington, MA, USA) [39].

2.2. Temperature Calculations

The general heat generation process involves optical absorption, heat generation by itself and heat transfer to the surrounding medium. For the mechanism of heat release, the electric field strongly drives mobile carriers inside the NPs, and the energy gained turns into heat. Then, the heat diffuses away from the NP and leads to an increase of the temperature of the surrounding medium [40]. In metallic nanoparticles, the heat generation rate is especially strong under plasmon resonance. However, in semiconductors, this is much weaker since heat dissipation occurs through an interband absorption process with the creation of a single mobile electron-hole pair (exciton). In absence of phase transformations, the temperature distribution around an optically excited NP is described by the heat transfer equation [40,41]

$$o(\mathbf{r})c(\mathbf{r})\frac{\partial T(\mathbf{r},t)}{\partial t} = \nabla k(\mathbf{r})\nabla T(\mathbf{r}) + Q_e(\mathbf{r},t),\tag{3}$$

where r and t are the spatial coordinate and time, respectively. T(r,t) is the local temperature, and the material parameters $\rho(r)$, c(r) and $\kappa(r)$ are the density, specific heat and thermal conductivity, respectively. The magnitude $Q_e(r,t)$ represents a heat source produced by light dissipation in NPs. This term is composed by both resistive and magnetic losses. $Q_e(r,t)$ has been obtained by solving a system of Maxwell's equations including appropriate boundary conditions [5]. In our case, the whole process of light absorption and subsequent heat transfer between the nanostructure and the surrounding medium has been modeled by means of finite element simulations implemented in COMSOL Multiphysics 5.2 [39] (following the same method as in [2,3]).

3. Materials

In the search for materials with an appropriate HRI dielectric properties in the UV range, we look for real materials whose optical properties fulfill the two following constrains on their dielectric constant $\varepsilon = \varepsilon_1 + i\varepsilon_2$,

- A real part of the dielectric permittivity ε₁ > 4 in the UV allow the generation of electric and magnetic dipolar responses in the nanoparticle. This is necessary to satisfy the zero backward and minimum forward conditions.
- An imaginary part of the dielectric permittivity that meets the condition ε₂ < 1 at energies higher than 3 eV. This opens a low-absorption window above 3 eV, since it can be easily derived that, provided that ε₁ > ε₂, the corresponding imaginary part of the refractive index (n_i ≈ ε₂/2√ε₁) would be of the order of 0.1.

The materials we have analyzed that fulfill these requirements are the following: aluminum phosphide (AlP), aluminum arsenide (AlAs), aluminum nitride (AlN), diamond, cerium dioxide (CeO₂), and titanium dioxide (TiO₂). Table 1 shows the photon energy at which $\varepsilon_2 = 1$ for each of the selected materials. In the case of AlN and diamond, the photon energy at which this condition is reached is out of the spectral range considered in this study (1–6 eV).

Table 1. Photon energy at which $\varepsilon_2 = 1$ for each of the selected materials. For AlN and diamond, the dash indicates that the $\varepsilon_2 = 1$ is produced outside of the spectral range under study (1–6 eV).

Material	$E\left(\varepsilon_2=1\right)/\mathrm{eV}$
AlP	3.90
AlAs	3.25
AlN	-
Diamond	-
CeO ₂	3.53
TiO ₂	3.39

Some of the wide-bandgap materials have been rejected because they do not fulfill one of the two constraints. This includes GaN, ZnS, ZnO, and AlSb. For all the selected materials, with the exception of AlP and AlAs, NP fabrication methods have been reported and are available in the literature [35,42–44].

Figure 1a–f shows the dielectric permittivity ($\varepsilon = \varepsilon_1 + i\varepsilon_2$) of the selected materials. The region where $\varepsilon_1 > 4$ and $\varepsilon_2 < 1$ within the UV is shadowed in gray. In Figure 1g,h, the dielectric function of Rh and Al is shown as a reference because these metals are widely used in UV plasmonic applications [20]. Figure 1i plots the dielectric permittivity of the HRI dielectric materials taken as reference, like Si, GaAs and Ge. In the case of the reference materials (Al, Rh, Si, GaAs, and Ge) the shadowed region indicates the UV spectral range.



Figure 1. Real (solid line) and imaginary (dashed line) parts of the dielectric permittivity ($\varepsilon = \varepsilon_1 + i\varepsilon_2$) of (**a**) AlP [45], (**b**) AlAs [46], (**c**) AlN [47], (**d**) diamond, (**e**) CeO₂ [48], (**f**) TiO₂ [49], (**g**) Al, (**h**) Rh [50] and (**i**) dielectrics taken as reference like Si (blue), GaAs (yellow) and Ge (red) [50]. The region in which $\varepsilon_2 < 1$ and $\varepsilon_1 > 4$ within the UV is shadowed in gray. In the case of the reference materials (Al, Rh, Si, GaAs and Ge) the shadowed region indicates the UV spectral range.

4. Results

4.1. Near-Field Enhancement

Near-field enhancement produced by NPs when electromagnetically irradiated is essential for applications like SERS (surface enhanced Raman spectroscopy) or SEF (surface enhanced fluorescence). In these spectroscopy techniques, most of the NP surface is covered with the molecules under study, so the electromagnetic field acting on them can be approximated by an average of the electric field produced over the whole NP surface [6,21,51]. Figure 2 shows the near-field enhancement averaged over the NP surface $\langle |E| / |E_0| \rangle$. Spheres with *R* varying from 30 to 90 nm have been considered. With dashed and solid white lines are highlighted the energy at which $\varepsilon_2 = 1$ and the starting energy of the UV regime respectively (3 eV). For reference, $\langle |E| / |E_0| \rangle$ for two common metals for UV

plasmonic applications are included: Rh and Al. In the case of Al, a realistic 5 nm thick oxide (Al_2O_3) shell has been considered [52,53].



Figure 2. Near-field enhancement averaged over the surface $\langle |E| / |E_0| \rangle$ of spheres with radius *R* (between 30 and 90 nm). A white dashed line represents the energy where $\varepsilon_2 = 1$, and a white solid line indicates the energy where we consider the UV regime starts, 3 eV.

Unlike Si, all the HRI dielectric materials analyzed in this research, exhibit its electric field enhancement at energies above 3 eV. AlP, AlAs, CeO₂ and TiO₂ also show similar performance and high values of $\langle |E| / |E_0| \rangle$ can be reached between 3 and 3.4 or 4 eV depending on the material. We would like to emphasize that TiO₂ shows the largest enhancement at energies above 3 eV. AlN and diamond also have very similar behavior since their absorption bands are above 6 eV: they have a HRI dielectric like behavior all along the studied spectral range. In this case, diamond presents the highest enhancement.

The values of $\langle |E| / |E_0| \rangle$ for Al (with its native oxide shell included) and Rh NPs are also shown for comparison. Rhodium presents very low enhancement because its LSPRs are into deep UV (above 6 eV) [20,30]. On the contrary, Al/Al₂O₃ nanospheres present wider peaks with moderate intensity. Consequently, the value of $\langle |E| / |E_0| \rangle$ is almost constant for all sizes in the studied spectral range.

4.2. Directionality Properties: The Full-Forward Condition

The full-forward condition, also known as the first Kerker condition, maximizes the scattered intensity in the forward direction while it minimizes the backward one. This situation has found a great utility in light guiding and light trapping applications [11,54–57].

In order to evaluate the full-forward condition, we have considered nanospheres of different radii made of AIP, AIAs, AIN, CeO₂, TiO₂ and Si and we have analyzed the following parameters: photon

energy where the zero-backward condition is produced (E_{ZB}), the scattering efficiency (Q_{sca}) and the forward to backward scattering ratios (I_{Fwd}/I_{Bck}) at E_{ZB} . In addition, the combined effect of these two last magnitudes, the *zero backward efficiency*, defined as $Q_{ZB} = Q_{sca} \cdot I_{Fwd}/I_{Bck}$ will be also analyzed.

Figure 3a shows the photon energies where the zero-backward condition holds (E_{ZB}) for spheres of radius *R* between 30 and 90 nm. The zero-forward condition is not satisfied for all the materials in the analyzed size range. For example, for CeO₂ NPs, *R* should be larger than 60 nm. On the contrary, nanospheres made of either AlP or diamond, exhibit this condition for all analyzed radii. The rest of materials also shows the zero-backward condition in the UV but not for all radii. Notice that all of them satisfy this condition at higher energies than Si. Those that show the zero-backward condition above 3 eV are AlP ($30 \le R \le 50$ nm), AlN ($40 \le R \le 80$ nm), diamond ($40 \le R \le 70$ nm), CeO₂ ($60 \le R \le 80$ nm), and TiO₂ (R = 50 nm).



Figure 3. (a) Photon energies where the zero-backward condition holds (E_{ZB}), (b) scattering efficiency Q_{sca} at the photon energy of the zero-backward condition, (c) forward to backward intensity ratio I_{Fwd}/I_{Bck} at the zero-backward condition and (d) zero backward efficiency, Q_{ZB} , for spheres of radius *R* (between 30 and 90 nm) made of different materials.

High values of Q_{sca} are desirable in order to exploit the maximum amount of incoming intensity in the analyzed condition, the zero-backward [38]. Figure 3b shows the scattering efficiency Q_{sca} at the photon energy of the zero-backward condition as a function of the sphere radius, *R*. Among the studied materials, those that show the highest values of Q_{sca} at the zero-backward condition are diamond, CeO₂ and AlN. AlP, one of the promising candidates for directionality applications in the UV, presents values of Q_{sca} around two times smaller than diamond and CeO₂, and very similar to those of TiO₂. It is worth noting that all the analyzed materials show higher values of Q_{sca} than Si.

Figure 3c shows the forward to backward intensity ratio I_{Fwd}/I_{Bck} at the photon energy of the zero-backward condition as a function of *R*. This magnitude will allow us to quantify the asymmetry introduced in the scattered intensity along the propagating direction when imposing the zero-backward conditions. Diamond, CeO₂ and AlN are the materials that present higher ratios I_{Fwd}/I_{Bck} . Values remain almost constant for all the considered sizes. TiO₂ and AlP present the same values of I_{Fwd}/I_{Bck} , and very similar to that of AlAs. Once again, Si shows the lowest ratio.

The ideal zero backward condition is a combination of two effects: a high scattering efficiency and a high forward to backward ratio. Therefore, forward directionality requires the presence of both. This makes it necessary to evaluate the *zero backward efficiency*, defined as $Q_{ZB} = Q_{sca} \cdot I_{Fwd} / I_{Bck}$. Figure 3d shows the values of Q_{ZB} at the photon energy of the zero-backward condition as a function of *R*. Diamond, CeO₂ and AlN present the same constant value of Q_{ZB} , approximately. The zero backward efficiency for AlP and TiO₂ takes the same values. However, in this case, Q_{ZB} becomes smaller as *R* decreases. Once again, Si is the material that shows the worst performance. Therefore, all the analyzed materials are better options than Si for scattering directionality applications, in both the VIS and UV ranges.

4.3. Interaction Effects

In this section, possible interaction effects are considered by studying the near-field enhancement that can be produced between two NPs in close interaction and the consequences that this interaction may have in the heat generation process. Interaction effects are widely used when designing nanostructures for surface enhanced spectroscopic techniques [6]. A dimer made of spheres with R = 70 nm and interparticle distances (gap) of 10 and 20 nm are analyzed.

TiO₂ and diamond are selected as representative materials of the two types of HRI dielectrics studied previously: those with losses ($\varepsilon_2 > 0$) above 3.5 eV (AlP, AlAs, CeO₂ and TiO₂) and those with losses above 6 eV (AlN and diamond). The selected materials for this study (TiO₂ and diamond) when studied as isolated spheres, showed the highest value of $\langle |E| / |E_0| \rangle$. We also present the behavior of Al NPs as a reference. Once again, a 5 nm oxide shell (Al₂O₃) has been considered in order to mimic common experimental situations [52].

Figure 4 shows the spectral values of $|E| / |E_0|$ and ΔT (temperature increase with respect to ambient temperature) at the center of the gap of dimers made of Al + Al₂O₃, TiO₂ and diamond. In all cases, the dimers are excited with a plane wave linearly polarized along the dimer axis (see inset in Figure 4a). This polarization is chosen to enhance the interaction effects [58]. By comparing the values of $|E| / |E_0|$ for the different materials analyzed, both diamond and TiO₂ produce the highest values above 3 eV. In the case of the Al + Al₂O₃ dimer, the enhancement is significantly smaller than that of either diamond or TiO₂ (around 4 times and one order of magnitude, respectively) and at an energy slightly below 3 eV. Also note that, for diamond and TiO₂, the temperature does not increase ($\Delta T = 0$) when excited at the photon energies of maximum enhancement. However, for Al/Al₂O₃, the temperature is increased



Figure 4. Electric field enhancement $|E| / |E_0|$ (blue line, left axis) and temperature difference with respect to ambient temperature ΔT (red line, right axis) at the center of the gap of (**a**) Al + Al₂O₃, (**b**) TiO₂ and (**c**) diamond dimers. The analyzed dimer configuration is shown as inset in (**a**): a dimer of spheres of *R* = 70 nm with gap = 10 (dashed line) and 20 nm (solid line), illuminated with a plane wave linearly polarized along the dimer axis.

Similar results to those of TiO₂ are expected for AlP, AlAs and CeO₂: high values of $|E| / |E_0|$ and low values of ΔT at energies below their corresponding absorption bands (\approx 3.5 eV). At higher

energies, ΔT increases while $|E| / |E_0|$ decreases. Also, mention that for AlN, a behavior similar to diamond is expected, moderate values of $|E| / |E_0|$ with $\Delta T = 0$ for energies below 6 eV.

The main difference between having a gap of 10 or 20 nm is that for the shortest one both $|E| / |E_0|$ and ΔT , are higher. This is caused by the strength of the interaction: as the distance between particles become smaller the interaction becomes stronger. Also, a red-shift of both $|E| / |E_0|$ and ΔT spectra is produced as the gap becomes shorter [58].

Figure 5 shows the near-field enhancement ($|E| / |E_0|$) and heat maps (ΔT) for diamond and Al + Al₂O₃ dimers with a gap = 20 nm. Since the temperature increment is proportional to the intensity of the illuminating beam, the temperature scale is arbitrary and for comparison purposes, going from 0 to a maximum value that depends on this intensity [40]. The diamond dimer offers the highest near field enhancement, together with the smallest heat perturbation. However, this is not the case for Al + Al₂O₃, where the field enhancement is four times smaller and significant heat generation is present, as expected from its absorption [53]. Although the results for gap = 10 nm are not shown, the overall effect of decreasing the gap is an increase of the near-field enhancement and temperature at the center of the gap, while keeping a very similar $|E| / |E_0|$ and ΔT spatial distribution [2].



Figure 5. Near field |E|/|E0| (**top** row) and temperature difference ΔT (**bottom** row) maps for a diamond and Al/Al2O3 dimers with gap = 20 nm. Both dimers are illuminated at resonance (photon energy indicated as a inset), with a p-polarized beam E and wave vector k. E_{photon} corresponds to the photon energy of the illuminating beam. The chosen values of E_{photon} are those that produce the maximum near-field enhancement at the center of the gap.

5. Conclusions

We have explored the possibilities of a selection of semiconductors—of the low loss High Refractive Index kind—to form nanoparticles with interesting applications in the UV region. The behavior we have considered of interest includes acting as HRI nanoantennas or behaving as unit cells of more complex metamaterials. The analyzed materials include some important semiconductors like AlP, AlAs, AlN, diamond, CeO₂ and TiO₂. When studying its near field—averaged over the surface of the nanoparticle—some important values of the enhancement have been observed within the UV range in most of the considered materials. In the far field, the possibility of using nanoparticles of these materials to generate light directionality effects has been explored by means of the zero-backward efficiency, which accounts for both the scattering efficiency and the backward-to-forward scattering ratio. In fact, all the analyzed materials are better options than Si for scattering directionality applications, both in the VIS and UV ranges. Finally, the near-field enhancement and local temperature effects have been studied for these materials when forming dimers, reaching high values of the near field, similar to the response of well-known semiconductors used in VIS and near-IR (Si, GaAs, and Ge).

Based on these analyses, some of the studied compounds can be considered as promising High Refractive Index dielectrics in the UV. On the one hand there is diamond, along with AlN, that show loss-less behavior below 6 eV, so they have HRI dielectric character in the entire optical regime (from near-IR to UV). They exhibit the highest values of Q_{ZB} , only matched by CeO₂, but with moderate values of $|E| / |E_0|$ all along the UV range. On the other hand, TiO₂, along with AlP, AlAs and CeO₂, present losses above ≈ 3.5 eV. Between 3 and 3.5 eV they present high values of $|E| / |E_0|$ but lower Q_{ZB} values than AlN and diamond.

Finally, the analysis of the thermal response in the case of dimers shows that, for both TiO_2 and diamond, high values of $|E| / |E_0|$ can be generated at energies above 3 eV without any losses and consequently no heat.

Author Contributions: Y.G. and F.M. conceived the original idea. Y.G. carried out the numerical calculations and wrote the paper. All authors analyzed the results and reviewed the manuscript. P.A. and F.M. supervised the study.

Funding: This research has been supported by the Army Research Laboratory under Cooperative Agreement Number W911NF-17-2-0023 and by SODERCAN (Sociedad para el Desarrollo de Cantabria) through the Research Vicerrectorate of the University of Cantabria.

Acknowledgments: Y.G. wants to thank the University of Cantabria for her FPU grant. P.A also acknowledges funding from the Ramon y Cajal Fellowship RYC-2016-20831.

Conflicts of Interest: The authors declare no conflict of interest.

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